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Multiple Scattering Suppression in Laser Light Scattering

Older **laser**-light-scattering methods for determining **particle sizes** from cross- or autocorrelation of **photodetector** outputs entail various deficiencies and ...

www.nasatech.com/Briefs/Nov99/LEW16517.html - 8k -

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The avalanche **photodetector** then converts the light pulses into electrical pulses. Two partially overlapping **laser beams** allow each **particle** to generate a ...

www.epa.gov/etv/pdfs/vrvs/01_vs_tsi_3320aps.pdf - [Similar pages](#)

Optical / Photodetector

High-speed, low-cost, compact optical detector / **photodetector** module
www.lightility.com

Laser Detector?

Brief and Straightforward Guide to Radar Detectors
wisegeek.com

SOAR fleet

Light scattered by a **particle** entering the **laser beam** is collected and focused onto a ... The **particle sizing** data is updated at 1-second intervals. ...

www.sandylandwater.com/research_aircraft.htm - 24k - [Cached](#) - [Similar pages](#)

Dynamic Light Scattering | Ultrafine Particle Analyzer | PSA | PSD ...

... and returns the scattered and the reflected **beams** to the **photodetector**. ... **Particle Size Analyzer | Particle Size Distribution | PSA | PSD | Laser ...**

www.microtrac.com/dynamicscattering.cfm - 28k - [Cached](#) - [Similar pages](#)

[PDF] The Next Generation PDPA/LDV Systems

File Format: PDF/Adobe Acrobat

generates the **laser beams** needed for one-, two- or three-component PDPA/LDV systems. ... velocity and **particle size** fields. Details of flow and **particle** ...

www.tsi.com/documents/PDPA.pdf - [Similar pages](#)

FSSP-300

A Helium Neon **laser beam** is focused to a small diameter at the center of an ... The **size** of the **particle** is determined by measuring the light scattering ...

raf.atd.ucar.edu/Bulletins/B24/fssp300.html - 8k - [Cached](#) - [Similar pages](#)

PCASP-100

A Helium Neon **laser beam** is focused to a small diameter at the center an ... DBARP Average Diameter Arithmetic average of **particle size** - micrometers ...

raf.atd.ucar.edu/Bulletins/B24/pcasp100.html - 6k - [Cached](#) - [Similar pages](#)

Available equipment

Shadow images of cloud **particles** in a **size** range between 25 and 800 μm are focused ... The distance along the **laser beam**, where crossing **particles** produce a ...

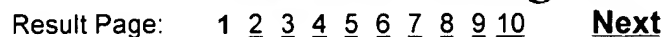
w3.gkss.de/Pms/probes1.htm - 16k - [Cached](#) - [Similar pages](#)







[doc] Use of Particle Counters for measuring Water Treatment Plant ...

File Format: Microsoft Word 97 - [View as HTML](#)

Fluctuations in the light **beam** are measured by the **photodetector**. **Particles** in the sample

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particle size, laser beam, photodetector Search

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Inventor Name Search Result

Your Search was:

Last Name = MORIYA

First Name = TSUYOSHI

| Application# | Patent# | Status | Date Filed | Title | Inventor Name |
|--------------------------|-------------------------|--------|------------|---|------------------|
| 09273293 | 6306770 | 150 | 03/19/1999 | METHOD AND APPARATUS FOR PLASMA ETCHING | MORIYA, TSUYOSHI |
| 09290636 | 6184489 | 150 | 04/12/1999 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | MORIYA, TSUYOSHI |
| 09413590 | 6115120 | 150 | 10/06/1999 | SYSTEM AND METHOD FOR DETECTING PARTICLES PRODUCED IN A PROCESS CHAMBER BY SCATTERING LIGHT | MORIYA, TSUYOSHI |
| 09443050 | Not Issued | 164 | 11/18/1999 | PARTICLE DETECTION SYSTEM AND METHOD USING MONITORED OPERATING CONDITIONS OF A PROCESS CHAMBER | MORIYA, TSUYOSHI |
| 09651186 | 6346425 | 150 | 08/30/2000 | Vapor-phase processing method capable of eliminating particle formation | MORIYA, TSUYOSHI |
| 09656713 | Not Issued | 71 | 09/07/2000 | Apparatus for monitoring particles and method of doing the same | MORIYA, TSUYOSHI |
| 09685351 | 6423176 | 150 | 10/10/2000 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | MORIYA, TSUYOSHI |
| 09721703 | 6737666 | 150 | 11/27/2000 | APPARATUS AND METHOD FOR DETECTING AN END POINT OF A CLEANING PROCESS | MORIYA, TSUYOSHI |

| | | | | | |
|-----------------|------------|-----|------------|---|------------------|
| <u>09767960</u> | Not Issued | 161 | 01/24/2001 | Dust particle removing method and apparatus, impurity detecting method and system | MORIYA, TSUYOSHI |
| <u>09950759</u> | Not Issued | 161 | 09/13/2001 | Semiconductor fabrication device and method for preventing the attachment of extraneous particles | MORIYA, TSUYOSHI |
| <u>09962169</u> | Not Issued | 161 | 09/24/2001 | Semiconductor device manufacturing apparatus and method for manufacturing a semiconductor device | MORIYA, TSUYOSHI |
| <u>09971463</u> | Not Issued | 83 | 10/05/2001 | Particle-removing apparatus for a semiconductor device manufacturing apparatus and method of removing particles | MORIYA, TSUYOSHI |
| <u>10166303</u> | Not Issued | 71 | 06/11/2002 | Method of manufacturing semiconductor devices and semiconductor manufacturing apparatus | MORIYA, TSUYOSHI |
| <u>10722602</u> | Not Issued | 30 | 11/28/2003 | Internal member of a plasma processing vessel | MORIYA, TSUYOSHI |
| <u>10773245</u> | Not Issued | 30 | 02/09/2004 | Plasma processing apparatus, ring member and plasma processing method | MORIYA, TSUYOSHI |
| <u>10858049</u> | Not Issued | 30 | 06/02/2004 | Substrate processing apparatus and substrate transferring method | MORIYA, TSUYOSHI |
| <u>10920367</u> | Not Issued | 30 | 08/18/2004 | Particle removal apparatus and method and plasma processing apparatus | MORIYA, TSUYOSHI |
| <u>10921947</u> | Not Issued | 30 | 08/20/2004 | Method for cleaning elements in vacuum chamber and apparatus for processing substrates | MORIYA, TSUYOSHI |
| <u>10959197</u> | Not Issued | 30 | 10/07/2004 | Particle sticking prevention apparatus and plasma processing apparatus | MORIYA, TSUYOSHI |
| <u>11065359</u> | Not Issued | 20 | 02/25/2005 | Processing apparatus and method for removing particles therefrom | MORIYA, TSUYOSHI |
| <u>11091416</u> | Not Issued | 20 | 03/29/2005 | Plasma processing apparatus and method | MORIYA, TSUYOSHI |
| <u>11091417</u> | Not Issued | 20 | 03/29/2005 | Vacuum apparatus including a particle monitoring unit, particle monitoring method and program, and window member for use in the particle monitoring | MORIYA, TSUYOSHI |
| | | | | | |

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|-----------------|------------|-----|------------|--|------------------|
| <u>11115357</u> | Not Issued | 19 | 04/27/2005 | Substrate transfer device and cleaning method thereof and substrate processing system and cleaning method thereof | MORIYA, TSUYOSHI |
| <u>11115358</u> | Not Issued | 30 | 04/27/2005 | Substrate cleaning apparatus and method | MORIYA, TSUYOSHI |
| <u>11128256</u> | Not Issued | 20 | 05/13/2005 | Substrate transfer mechanism and substrate transfer apparatus including same, particle removal method for the substrate transfer mechanism and apparatus, program for executing the method, and storage medium for storing the program | MORIYA, TSUYOSHI |
| <u>11171236</u> | Not Issued | 20 | 07/01/2005 | Apparatus for inspecting a surface of an object to be processed | MORIYA, TSUYOSHI |
| <u>60589807</u> | Not Issued | 159 | 07/22/2004 | Transfer apparatus and processing system of workpieces and method thereof | MORIYA, TSUYOSHI |
| <u>60589808</u> | Not Issued | 159 | 07/22/2004 | Method and apparatus for cleaning workpieces | MORIYA, TSUYOSHI |
| <u>60589810</u> | Not Issued | 159 | 07/22/2004 | Particle monitor and processing system with particle monitor | MORIYA, TSUYOSHI |
| <u>60598425</u> | Not Issued | 159 | 08/04/2004 | Apparatus for inspecting surface of workpiece | MORIYA, TSUYOSHI |
| <u>60626467</u> | Not Issued | 20 | 11/10/2004 | Apparatus for plasma processing, and method, computer program and recording medium | MORIYA, TSUYOSHI |
| <u>60635615</u> | Not Issued | 20 | 12/14/2004 | Method, apparatus, computer program and recording medium for cleaning substrate, and system for processing substrate | MORIYA, TSUYOSHI |
| <u>60635617</u> | Not Issued | 20 | 12/14/2004 | Vacuum apparatus, method for particle monitor thereof, computer program for the method and window member for particle monitor | MORIYA, TSUYOSHI |
| <u>60635942</u> | Not Issued | 20 | 12/15/2004 | System and apparatus for transferring substrate, method for removing particle thereof, computer program for the method and recording medium for the computer program | MORIYA, TSUYOSHI |
| <u>60635945</u> | Not Issued | 20 | 12/15/2004 | Controlling method for substrate-processing apparatus, substrate- | MORIYA, TSUYOSHI |

| | | | | | |
|-----------------|----------------|-----|------------|---|--------------------|
| | | | | processing apparatus, computer program for the method | |
| <u>60635968</u> | Not Issued | 20 | 12/15/2004 | Member for substrate processing apparatus and method for making the same | MORIYA, TSUYOSHI |
| <u>60635970</u> | Not Issued | 20 | 12/15/2004 | Ceramic-sprayed member, method for cleaning the same, computer program for the method and recording medium for the computer program | MORIYA, TSUYOSHI |
| <u>60650956</u> | Not Issued | 20 | 02/09/2005 | Cleaning method of processing apparatus, computer program for performing the method, and recording medium for storing the program | MORIYA, TSUYOSHI |
| <u>60662794</u> | Not Issued | 20 | 03/18/2005 | Member for introducing gas and plasma processing apparatus using the same | MORIYA, TSUYOSHI |
| <u>60663187</u> | Not Issued | 20 | 03/21/2005 | Reflection device, manifold and vacuum pump for exhausting gas, and exhaust system therewith | MORIYA, TSUYOSHI |
| <u>60666703</u> | Not Issued | 20 | 03/31/2005 | Atmospheric transfer module | MORIYA, TSUYOSHI |
| <u>60666717</u> | Not Issued | 20 | 03/31/2005 | Method of removing moisture from vacuum vessel, computer program of executing the method and storage medium of the program | MORIYA, TSUYOSHI |
| <u>08680863</u> | <u>5889596</u> | 150 | 07/16/1996 | CONTROLLING A READING UNIT OF AN IMAGE PROCESSING APPARATUS | MORIYAMA, TSUYOSHI |
| <u>08843271</u> | <u>6094510</u> | 150 | 04/14/1997 | IMAGE PROCESSING APPARATUS AND METHOD FOR PREDICTING A COMPRESSION RATE OF IMAGE DATA PROCESSED TO MODIFY AN IMAGE | MORIYAMA, TSUYOSHI |
| <u>09092091</u> | <u>6413884</u> | 150 | 06/05/1998 | METHOD OF PRODUCING THIN FILMS USING CURRENT OF PROCESS GAS AND INERT GAS COLLIDING WITH EACH OTHER | MORIYAMA, TSUYOSHI |
| <u>09261955</u> | <u>6337970</u> | 150 | 03/03/1999 | IMAGE FORMING APPARATUS HAVING SHEET PROCESSOR | MORIYAMA, TSUYOSHI |
| <u>09282489</u> | <u>6391116</u> | 150 | 03/31/1999 | SEMICONDUCTOR DEVICE | MORIYAMA, |

| | | | | | |
|--------------------------|-------------------------|-----|------------|--|--------------------|
| | | | | MANUFACTURING APPARATUS AND SEMICONDUCTOR DEVICE MANUFACTURING METHOD | TSUYOSHI |
| 09418590 | 6263173 | 150 | 10/15/1999 | Image formation apparatus having selection of different image types for image formation | MORIYAMA, TSUYOSHI |
| 09438525 | 6219503 | 150 | 11/12/1999 | SHEET PROCESSING APPARATUS AND METHOD WITH MULTI-MODE SHEET CONVEYING | MORIYAMA, TSUYOSHI |
| 09438527 | 6386080 | 150 | 11/12/1999 | SHEET PROCESSOR THAT ADJUSTS A PUNCHING OPERATION POSITION BASED ON A DETECTED SHEET EDGE AND ASSOCIATED IMAGE FORMING APPARATUS | MORIYAMA, TSUYOSHI |

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Inventor Name Search Result

Your Search was:

Last Name = ITO

First Name = NATSUOKO

| Application# | Patent# | Status | Date Filed | Title | Inventor Name |
|--------------------------|-------------------------|--------|------------|---|---------------|
| 08252656 | Not Issued | 161 | 06/01/1994 | ACCELERATION SENSOR | ITO, NATSUOKO |
| 08541266 | 5747991 | 150 | 10/12/1995 | CAPACITANCE TYPE ACCELERATION SENSOR | ITO, NATSUOKO |
| 08837942 | 5870189 | 150 | 04/28/1997 | PARTICLE MONITOR AND PARTICLE-FREE RECESSING SYSTEM WITH PARTICLE MONITOR | ITO, NATSUOKO |
| 08989630 | 5861951 | 150 | 12/12/1997 | PARTICLE MONITORING INSTRUMENT | ITO, NATSUOKO |
| 09070750 | 6042650 | 150 | 05/01/1998 | PROCESSING APPARATUS FOR FABRICATING LSI WITH PROTECTED BEAM DAMPER | ITO, NATSUOKO |
| 09273293 | 6306770 | 150 | 03/19/1999 | METHOD AND APPARATUS FOR PLASMA ETCHING | ITO, NATSUOKO |
| 09290636 | 6184489 | 150 | 04/12/1999 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | ITO, NATSUOKO |
| 09413590 | 6115120 | 150 | 10/06/1999 | SYSTEM AND METHOD FOR DETECTING PARTICLES PRODUCED IN A PROCESS CHAMBER BY SCATTERING LIGHT | ITO, NATSUOKO |
| 09443050 | Not Issued | 164 | 11/18/1999 | PARTICLE DETECTION SYSTEM AND METHOD USING MONITORED OPERATING CONDITIONS OF A PROCESS CHAMBER | ITO, NATSUOKO |
| 09504435 | 6284049 | 150 | 02/15/2000 | Processing APPARATUS FOR FABRICATING LSI DEVICES | ITO, NATSUOKO |

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|--------------------------|-------------------------|-----|------------|---|--------------|
| 09651186 | 6346425 | 150 | 08/30/2000 | Vapor-phase processing method capable of eliminating particle formation | ITO, NATSUKE |
| 09656713 | Not Issued | 71 | 09/07/2000 | Apparatus for monitoring particles and method of doing the same | ITO, NATSUKE |
| 09685351 | 6423176 | 150 | 10/10/2000 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | ITO, NATSUKE |
| 09721703 | 6737666 | 150 | 11/27/2000 | APPARATUS AND METHOD FOR DETECTING AN END POINT OF A CLEANING PROCESS | ITO, NATSUKE |
| 09767960 | Not Issued | 161 | 01/24/2001 | Dust particle removing method and apparatus, impurity detecting method and system | ITO, NATSUKE |
| 09950759 | Not Issued | 161 | 09/13/2001 | Semiconductor fabrication device and method for preventing the attachment of extraneous particles | ITO, NATSUKE |
| 09962169 | Not Issued | 161 | 09/24/2001 | Semiconductor device manufacturing apparatus and method for manufacturing a semiconductor device | ITO, NATSUKE |
| 09971463 | Not Issued | 83 | 10/05/2001 | Particle-removing apparatus for a semiconductor device manufacturing apparatus and method of removing particles | ITO, NATSUKE |
| 10166303 | Not Issued | 71 | 06/11/2002 | Method of manufacturing semiconductor devices and semiconductor manufacturing apparatus | ITO, NATSUKE |
| 09236593 | Not Issued | 161 | 01/26/1999 | PHARMACEUTICAL COMPOSITIONS FOR THE TREATMENT OF ISCHEMIC BRAIN DAMAGE | ITO, NATSUKE |

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Inventor Name Search Result

Your Search was:

Last Name = UESUGI

First Name = FUMIHIKO

| Application# | Patent# | Status | Date Filed | Title | Inventor Name |
|--------------------------|-------------------------|--------|------------|---|------------------|
| 07123460 | 4873413 | 150 | 11/20/1987 | METHOD AND APPARATUS FOR WRITING A LINE ON A PATTERNED SUBSTRATE | UESUGI, FUMIHIKO |
| 07717603 | 5393577 | 150 | 06/19/1991 | METHOD FOR FORMING A PATTERNED LAYER BY SELECTIVE CHEMICAL VAPOR DEPOSITION | UESUGI, FUMIHIKO |
| 08837942 | 5870189 | 150 | 04/28/1997 | PARTICLE MONITOR AND PARTICLE-FREE RECESSING SYSTEM WITH PARTICLE MONITOR | UESUGI, FUMIHIKO |
| 08989630 | 5861951 | 150 | 12/12/1997 | PARTICLE MONITORING INSTRUMENT | UESUGI, FUMIHIKO |
| 09070750 | 6042650 | 150 | 05/01/1998 | PROCESSING APPARATUS FOR FABRICATING LSI WITH PROTECTED BEAM DAMPER | UESUGI, FUMIHIKO |
| 09273293 | 6306770 | 150 | 03/19/1999 | METHOD AND APPARATUS FOR PLASMA ETCHING | UESUGI, FUMIHIKO |
| 09290636 | 6184489 | 150 | 04/12/1999 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | UESUGI, FUMIHIKO |
| 09413590 | 6115120 | 150 | 10/06/1999 | SYSTEM AND METHOD FOR DETECTING PARTICLES PRODUCED IN A PROCESS CHAMBER BY SCATTERING LIGHT | UESUGI, FUMIHIKO |
| 09443050 | Not Issued | 164 | 11/18/1999 | PARTICLE DETECTION SYSTEM AND METHOD USING MONITORED OPERATING CONDITIONS OF A PROCESS CHAMBER | UESUGI, FUMIHIKO |

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|--------------------------|-------------------------|-----|------------|---|------------------|
| 09504435 | 6284049 | 150 | 02/15/2000 | Processing APPARATUS FOR FABRICATING LSI DEVICES | UESUGI, FUMIHIKO |
| 09656713 | Not Issued | 71 | 09/07/2000 | Apparatus for monitoring particles and method of doing the same | UESUGI, FUMIHIKO |
| 09685351 | 6423176 | 150 | 10/10/2000 | PARTICLE-REMOVING APPARATUS FOR A SEMICONDUCTOR DEVICE MANUFACTURING APPARATUS AND METHOD OF REMOVING PARTICLES | UESUGI, FUMIHIKO |
| 09721703 | 6737666 | 150 | 11/27/2000 | APPARATUS AND METHOD FOR DETECTING AN END POINT OF A CLEANING PROCESS | UESUGI, FUMIHIKO |
| 09767960 | Not Issued | 161 | 01/24/2001 | Dust particle removing method and apparatus, impurity detecting method and system | UESUGI, FUMIHIKO |
| 09950759 | Not Issued | 161 | 09/13/2001 | Semiconductor fabrication device and method for preventing the attachment of extraneous particles | UESUGI, FUMIHIKO |
| 09962169 | Not Issued | 161 | 09/24/2001 | Semiconductor device manufacturing apparatus and method for manufacturing a semiconductor device | UESUGI, FUMIHIKO |
| 09971463 | Not Issued | 83 | 10/05/2001 | Particle-removing apparatus for a semiconductor device manufacturing apparatus and method of removing particles | UESUGI, FUMIHIKO |
| 10166303 | Not Issued | 71 | 06/11/2002 | Method of manufacturing semiconductor devices and semiconductor manufacturing apparatus | UESUGI, FUMIHIKO |

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